



## Application of Porous Materials in CO<sub>2</sub> Capture

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Deadline for manuscript  
submissions:

**closed (31 March 2023)**

### Message from the Guest Editors

In this Special Issue, we are looking for contributions helping to:

- Understand the CO<sub>2</sub> capture mechanisms through in situ and simulation analysis;
- Determine the impact of structural properties on the CO<sub>2</sub> capture materials' overall performance;
- Offer design principles of materials with high adsorption capacity and ideal adsorption selectivity for CO<sub>2</sub> capture;
- Develop CO<sub>2</sub> capture systems at the industry scale.

The topics of interest include but are not limited to:

- The design of CO<sub>2</sub> capture systems based on porous materials;
- Industry CO<sub>2</sub> technologies;
- Direct air capture technologies;
- Structure–activity relationship of CO<sub>2</sub> capture materials;
- CO<sub>2</sub> sorption modeling and simulation.





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## Message from the Editor-in-Chief

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